

Form PTO-1449

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APPLICATION NO.
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INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(Use several sheets if necessary)

APPLICANT
PARK et al.

FILING DATE
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GROUP

997 U.S. PTB

09/998131

12/03/01

U.S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

[illegible]

OTHER DOCUMENTS

OTHER DOCUMENTS (Include Name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published.

180	Van Den Hove, A Self-Aligned CoSi ₂ Interconnection and Contact Technology, IEEE Trans On Electron Device, pp. 554-561, 3/1997
181	Broadbent et al., Application Of Self-Aligned CoSi ₂ interconnection in Submicrometer CMOS Transistors, IEEE Transaction On Electron Devices, pp 2440-2446, 11/1989

EXAMINER

DATE CONSIDERED

ERED 08/09/02

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